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Title:Resonant properties of the planar plasmonic crystal on a membrane substrate
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Abstract:The theory of the plasmon resonance excitation in the plasmonic-crystal structure on a dielectric substrate is presented. The effect of the plasmon resonance intensity oscillation as a function of the substrate thickness is predicted. It is shown that the enhancement of the plasmon resonance intensity occurs in a broad terahertz frequency range in the structure on a membrane substrate. © 2012 Allerton Press, Inc.
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